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	Application No.	Applicant(s)	·
Notice of Allowability	10/004,489 Examiner	SUZUKI ET AL. Art Unit	
	Renee R Berry	2818	
The MAILING DATE of this communication appeal claims being allowable, PROSECUTION ON THE MERITS IS therewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT Report to 10 of the Office or upon petition by the applicant. See 37 CFR 1.313 of the This communication is responsive to 9/9/03.	(OR REMAINS) CLOSED in this ap or other appropriate communication IGHTS. This application is subject	oplication. If not include n will be mailed in due o	ed course, <b>THIS</b>
2. ☐ The allowed claim(s) is/are <u>1-8 and 10-18</u> .			
3. $\square$ The drawings filed on <u>23 October 2001</u> are accepted by th			
<ol> <li>Acknowledgment is made of a claim for foreign priority ur</li> <li>a)</li></ol>	nder 35 U.S.C. § 119(a)-(d) or (f).		
<ol> <li>Certified copies of the priority documents have</li> </ol>			
<ol><li>Certified copies of the priority documents have</li></ol>	• •		
<ol> <li>Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)).</li> </ol>	cuments have been received in this	s national stage applicat	ion from the
* Certified copies not received:			
<ol> <li>Acknowledgment is made of a claim for domestic priority u reference was included in the first sentence of the specifical</li> </ol>			a specific
<ul> <li>(a)  The translation of the foreign language provisional a</li> <li>6. Acknowledgment is made of a claim for domestic priority u in the first sentence of the specification or in an Application</li> </ul>	nder 35 U.S.C. §§ 120 and/or 121 s	since a specific referenc	ce was included
Applicant has THREE MONTHS FROM THE "MAILING DATE" or below. Failure to timely comply will result in ABANDONMENT of	f this communication to file a reply on this application. THIS THREE-MC	complying with the requ	irements noted EXTENDABLE.
7. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	nitted. Note the attached EXAMINEF es reason(s) why the oath or declar	R'S AMENDMENT or N ation is deficient.	OTICE OF
<ol> <li>CORRECTED DRAWINGS ( as "replacement sheets") must</li> <li>(a) ☐ including changes required by the Notice of Draftspers</li> <li>1) ☐ hereto or 2) ☐ to Paper No</li> </ol>	son's Patent Drawing Review(PTC		
<ul><li>(b) ☐ including changes required by the proposed drawing of (c) ☐ including changes required by the attached Examiner</li></ul>			
ldentifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on the draw the margin according to 37 CFR 1.121	rings in the front (not the I(d).	back) of
9.   DEPOSIT OF and/or INFORMATION about the depondant and DEPOSIT OF and/or INFORMATION about the depondent regarding REQUIREMENT FOR T	sit of BIOLOGICAL MATERIAL THE DEPOSIT OF BIOLOGICAL MA	must be submitted. N ATERIAL.	Note the
Attachment(s)			
1☐ Notice of References Cited (PTO-892)	5 Notice of Informal P	atent Application (PTO	-152)
2☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3☑ Information Disclosure Statements (PTO-1449 or PTO/SB/08), Paper No	6∐ Interview Summary	(PTO-413), Paper No	·
	/ Examiner's America		
4☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	8 Examiner's Stateme	ent of Reasons for Allov	vance
	David Nelms Supervisory Patent Examiner		
Technology Center 2800			

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**EXAMINER'S AMENDMENT** 

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be

submitted no later than the payment of the issue fee.

The application has been amended as follows: Cancel claims 19 and 20.

**REASONS FOR ALLOWANCE** 

The following is an examiner's statement of reasons for allowance: There is no prior art of record that teaches or suggests a method of depositing a halogen-doped

silicon oxide over metal lines by using gas mixtures having SiF<sub>4</sub>:SiH<sub>4</sub> ratios of 0.0 to 1.0.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Renee R Berry whose telephone number is (703) 305-4544. The examiner can normally be reached on M-F 9-5:30.

RRB

Spery

November 25, 2003

David Nelms
Supervisory Patent Examiner
Technology Center 2800